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Transcription of Near-Field Induced by Photo-Irradiation on a Film of Azo-Containing Urethane-Urea Copolymer

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We present that an intensity distribution of optical near field induced around photo-irradiated polystyrene spherical nanopariticles was transcribed on a film of azo-containing ure-thane-urea copolymer. The transcription was attained by a topographical change of the polymer surface, and the change was observed using an atomic force microscope. We have observed distinguishable dent surface structure using particles 28 nm in diameter.

Keywords: optical near field; azo polymer; photo-induced reaction; nanoparticle; transcription

INTRODUCTION

Taking advantage of an optical near field is one of the most promising technique for a nanometer scale fabrication such as high density optical storage and super fine lithography, because of overcoming the diffraction limit.[1] Photo-sensitive materials could be needed to develop the near-field technology, since an intensity of near field is mostly low. Many azobenzene derivatives, which transform the chemical structure by trans-cis photoisomerization, were investigated extensively due to their variable photo-sensitive phenomena, for example, reorientation of molecules^[2], controlling an orientation of liquid crystal^[2], inducing a phase transition of liquid crystal^[3] and forming a surface relief grating. [5][6] We synthesized polyurethanes, urethane-urea copolymers and polyesters^{[7][8]}, those are containing azo chromophore in their main chain structure, as nonlinear polymers. We fabricated a mode selective waveguide^[9] from the urethane-urea azo copolymer by controlling an anisotropic refractive index change caused by photobleaching. Furthermore, we have developed non-optically probing near-field microscopy using the urethane-urea copolymer containing azo moiety as photosensitive material and demonstrated to transcribe an intensity near-field distribution of optical around polymer spherical nanoparticle.[10] In this letter, we report the dependencies of the optical power and particle diameter on the deformation process.

EXPERIMENTAL

Urethane-urea copolymer containing azo chromophore was synthesized according to previous report. The chemical structure of the copolymer was shown in Fig. 1 (lower). The copolymer has a glass transition temperature of 145 °C measured by a difference scanning calorimeter, a maximum absorption at 475 nm determined by an absorption spectrometer and weight-average molecular weight of 170000 measured by gel-permeation chromatography. The thin film of the copolymer was spin-coated on glass substrate from the polymer solution dissolved in

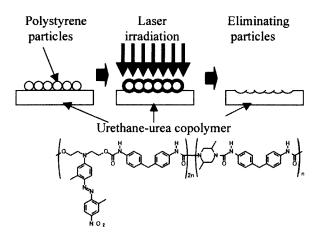


FIG. 1 Transcription process (upper) and chemical structure of the copolymer (lower)

pyridine after filtering through a $0.2 \mu m$ filter. The films obtained were dried under vacuum at room temperature for 6 h, at $100 \, ^{\circ}\text{C}$ for 20 h, and at $150 \, ^{\circ}\text{C}$ for 2 h.

An aqueous solution containing polystyrene monodisperse nanopartiles was dropped onto the polymer film and dried over night. Various kinds of particles having diameters ranging from 2000 nm to 28 nm was used The solution was purchased from MORITEX. An ordered monolayer of nanoparticles was formed on the azo polymer film by self-organizing process. Coherent light at 488 nm was irradiated to the sample using an Ar laser. After the irradiation, the nanoparticles were eliminated by washing with water, and then the sample was immersed in benzene to eliminate the residue of particles. The topographic image of the obtained film was observed using a Nanoscope atomic force microscopy (AFM). This process was shown schematically in Fig. 1 (upper).

RESULTS & DISCUSSION

Fig 2 a. b. and c show AFM images obtained from the experiments using 500-nm, 100-nm and 28-nm nanoparticles, respectively. These images showed arrayed dent structures, respectively. The hexagonal arrayed structure of nanoparticle was formed on the film by self-

organizing process; however, the structure was disordered in the case of particles, smaller small than 100 nm. The arrayed structure of nanoparticles was transferred in the images obtained from the photo-transcribed process. We also observed image of film on which the particles were remaining, so that identified the center of dent structure with the center of particle. deepest position of dent structure corresponded to of the point contact between sphere and azo We polymer. confirmed the images using scanning electron microscope.

Since the diameters of both the 100-nm and the

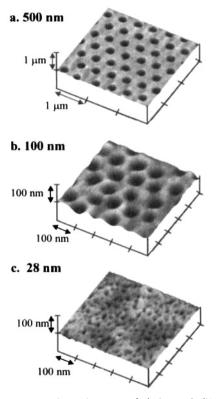


FIG. 2 AFM images of deformed film. The samples were prepared using photo-irradiated particles, a:500 nm, b:100 nm, c:28 nm

28-nm particle are smaller than the diffraction limit, and show Fig.2 optical transcriptions of field near onto azo The 28-nm copolymer. distinguished dent-structure corresponds to high-density optical recording of about 1 Tbit/in2.

The diameter of dent structure increased with nanoparticles, that of however. was not proportional to that of The nanoparticles. diameter of dent structure with unchanged was increasing the irradiated optical power under the same irradiation time. though the depth increased the power. Fig.3 shows the ratio of diameter between dent structure and nanoparticle. The ratio decreased with the diameter of particle and

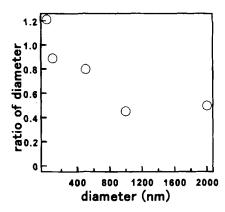


FIG. 3 Ratio of diameter between dent structure and nanoparticle as a function of the nanoparticle diameter

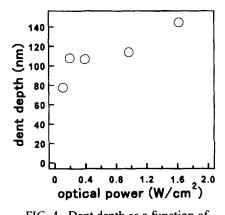


FIG. 4 Dent depth as a function of optical power. Irradiation was performed using nanoparticles of 500 nm in diameter.

saturated over 1000 nm. Fig. 4 shows the dent depth as a function of optical power. The dent depth increased depending on the power. In early stage the depth of dent structure rapidly increased with the power

and then the depth slowly increased to reach saturated state. The depth also increased with irradiation time. The saturated depth was almost same, about 100-150 nm, in the case of experiments using particles of 2000, 1000, and 500 nm. On the other hand, the depth decreased with decreasing the diameter of nanoparticles in the experiments using 100-nm and 28-nm particles.

Large particle having diameter over the diffraction limit works as a lens so that optical power is focused on the area around contact point between nanoparticle sphere and azopolymer film. The results indicate that the lens effect dominates the deformation process in large - particle experiments, and near field is transcribed to the polymer film in small-particle experiments.

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